Special Issue

Additive Manufacturing of Materials: Process and Applications

Message from the Guest Editors

This Special Issue on "Additive Manufacturing of Materials: Process and Applications" seeks high-quality works focusing on the latest novel advances of additive manufacturing technologies, processes, materials and mechanisms. Topics include, but are not limited to:

- Metallic material (pure metallic materials, composite metallic materials, high-entropy alloys, etc.) process and applications;
- Non-metallic material (ceramics, polymers, biomass materials, etc.) process and applications;
- Mechanism investigations into continuous additive manufacturing, heat and mass transfer;

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Deadline for manuscript submissions

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